Wet chemical deposition of ATO and ITO coatings using crystalline nanoparticles redisplaceable in solutions

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Abstract

The deposition of SnO$_2$:Sb (ATO) and In$_2$O$_3$:Sn (ITO) transparent conducting coatings on glass substrate has been demonstrated by many techniques such as CVD, sputtering, vacuum deposition and sol-gel process. This paper presents an alternative process for the deposition of such coatings at room temperature by spin, dip and spray coating techniques using solutions prepared with crystalline nanoparticles fully dispersed in water (for ATO, ITO) or alcohol (for ITO) with solid contents up to 10–15 Vol.%, respectively. The deposited green coatings have been sintered at temperatures as high as 900°C. In$_2$O$_3$:Sn coatings have a resistivity of 1.5 × 10$^{-7}$ Ω cm as sintered and 3.4 × 10$^{-8}$ Ω cm after annealing in nitrogen atmosphere. The resistivity of ATO single coatings shows a minimum $p = 1.7 \times 10^{-2}$ Ω cm after annealing at 550°C. SnO$_2$:Sb coatings present long term stability but the resistivity of annealed ITO coatings steadily increases with time to a value three times higher. All coatings have a high optical quality with transmission in the visible range larger than 90%.

Keywords: Indium tin oxide; Antimony; Tin oxide; Conductivity; Nanoparticles

1. Introduction

Transparent conducting oxides (TCO) deposited on glass materials in the field of optoelectronic devices such as solar cells, electroluminescence and liquid crystal displays [1]. The n-type semiconductors such as indium tin oxide In$_2$O$_3$:Sn (ITO) [2], fluorine or antimony doped tin dioxide (FTO, ATO), aluminium or gallium doped zinc oxide (AZO, GZO) are widely used as transparent electrodes in these applications. Practically all known coating processes have been used for their preparation [1–3].

The sol-gel route leads to coatings presenting a relatively high resistivity $p$. For SnO$_2$:Sb coatings the published values vary from 3 × 10$^{-3}$ Ω cm [4] and 2.1 × 10$^{-2}$ Ω cm [5] but the resistivity of In$_2$O$_3$:Sn is as small as $p = 8 \times 10^{-3}$ Ω cm [2]. SnO$_2$:Sb coatings have a higher mechanical and thermal stability than ITO coatings. The reasons for the low conductivity of sol-gel SnO$_2$:Sb and In$_2$O$_3$:Sn films is due to their high porosity (low density) [6] even after sintering at high temperature. Structures with large and closely packed crystallites as obtained by spray pyrolysis, sputtering and CVD processes exhibit higher electron mobility and carrier density and consequently lower electrical resistivity.

A new concept based on the use of solutions containing already densified crystalline SnO$_2$:Sb or In$_2$O$_3$:Sn nanoparticles have been developed for the preparation of coatings (Fig. 1). This work outlines the preparation of crystalline ATO and ITO nanoparticles fully redisplaceable in a solvent, the sol and particle characterisation and the optimisation of the dopant content with respect to the electrical resistivity. The paper also describes various coating procedures and discusses the influence of the densification temperature and sintering time on the optical and electrical properties of such coatings.

2. Experimental

SnO$_2$:Sb and In$_2$O$_3$:Sn powders were prepared by a controlled growth technique [7–9]. A solution of tin (IV) chloride or indium (III) chloride in ethanol containing 0.1–10 mol% of SbCl$_5$ or SnCl$_4$, respectively was added dropwise to an aqueous ammonia solution containing 10 wt.% (with respect to the oxide) of a surface modifying agent, β-alanine. The ATO suspensions were treated at 150°C and 10 bar for 3 h under hydrothermal conditions, the ITO suspensions at 80°C for 24 h under atmospheric pressure. The
resulting powders were isolated by centrifugation, washed with water several times and then dried at 60°C. The dried ITO powder was annealed at 300°C in a reducing atmosphere.

The powders were characterised by high resolution transmission electron microscopy (HRTEM-CM200 FEG, Philips) and X-ray diffraction (D500, Siemens). Their crystallite size was calculated using the Siemens software.

Colloidal suspensions of ATO were prepared by redispersing the dried powder in water at pH ≥ 9 using tetramethylammoniumhydroxide as dispersion agent. The suspensions were then treated with ultrasonic irradiation for 2 min and then stirred during 1 day. They are clear with a yellowish orange colour.

Dried ITO powder was mechanically redispersed in ethyleneglycol with a carbon acid as dispersion agent and the solution was then added to ethanol or water.

Both suspensions showed a blue colour. The solutions are stable with solid contents up to 10–15 Vol.% and do not present precipitation during several months. They were characterised by measurement of the zeta potential (Zetasizer, Malvern) and the hydrodynamic particle size (ultrasonic particle analyser, UPA).

SnO\textsubscript{2}:Sb coatings were prepared by spin coating process on clean 5 × 5 cm\textsuperscript{2} borofloat substrates using 500 μl of the dispersion and a final speed of 2000 rev./min for 15 s. The ITO films were prepared by dipping 7.5 × 2.5 cm\textsuperscript{2} clean silica substrates into the dispersion and withdrawing them at a constant speed of 3 mm/s. The thermal densification of the films was carried out in a furnace in air up to 900°C. The ITO coatings were annealed afterwards in a N\textsubscript{2} atmosphere at a temperature of 300°C.

The following characteristics of the coatings were measured: sheet resistance (4 point-technique), film thickness (P10 surface profiler, Tencor), roughness (scanning force microscopy, SFM), porosity (ASAP2400, Micromeritics, surface acoustic wave (SAW), self made instrument) and optical reflection and transmission (Cary 5E, Varian).

3. Results and discussion

3.1. Powder and sol characterisation

The structure of dried SnO\textsubscript{2}, SnO\textsubscript{2}:Sb and In\textsubscript{2}O\textsubscript{3}:Sn measured: sheet resistance (4 point-technique), film thickness (P10 surface profiler, Tencor), roughness (scanning force microscopy, SFM), porosity (ASAP2400, Micromeritics, surface acoustic wave (SAW), self made instrument) and optical reflection and transmission (Cary 5E, Varian).

![Fig. 2. (A) X-ray diffraction of dried nanoscaled, crystalline SnO\textsubscript{2} powder prepared by a controlled growth reaction at 150°C and 10 bar for 3 h. The vertical lines correspond to the data of the JCPDS database, Table 41-1145 (cassiterite structure). (B) X-ray diffraction of nanoscaled, crystalline SnO\textsubscript{2}:Sb powder prepared by a controlled growth reaction at 150°C and 10 bar for 3 h.](image-url)
powders are shown in Figs. 2 and 3, respectively. The particles are already crystalline and have a cassiterite structure for SnO2, SnO2:Sb and a cubic In2O3 phase for the ITO powder. The TO, ATO and ITO crystallites are not oriented. The crystallite size, calculated from the (110) peak, is 7 nm for SnO2 and 3 nm for SnO2:Sb (5 mol% Sb). A systematic decrease of the crystallite size was observed with increasing antimony content. The crystallite size of In2O3:Sn is 15 nm using the (222) peak.

For the preparation of the coatings the nanoscaled crystalline particles were redispersed in water (ATO, ITO) or in ethanol (ITO). The stability of the dispersion was determined by measuring the ζ potential and is strongly dependent on the pH of the solvent (Fig. 4). The isoelectric point of the surface modified ATO powder lies at pH_{iep} = 3.7 and the suspension is stable for pH > 8. The isoelectric point of the ITO suspension is pH_{iep} = 8.5 and the suspension is stable for pH < 6.

A typical hydrodynamic size distribution of the particles is shown in Fig. 5. The average values are identical to the values of the crystallite size determined from the X-ray measurement. These results indicate that the particles are fully dispersed down to the primary particle size and that each particle appears to be formed by a single crystallite.

The size of the particles was also confirmed by HRTEM (Figs. 6 and 7) with no evidence of aggregation. The aggregates seen in Fig. 7 for the ITO powder are due to the preparation method of the sample for the TEM experiment.

3.2. Film characterisation

The film thickness of ATO and ITO increases with the solid content in the dispersion. With solid content higher than 7 Vol.% (ATO) and 5 Vol.% (ITO) the coatings are too thick and cracks are observed. A dispersion of ATO particles with a solid content of 5.6 Vol.% leads to a single film thickness of 200 nm. A 400 nm thick single layer can be obtained with an ITO suspension of 21 wt.% solid content. Both coatings have no visible cracks. The resistivity and the
sheet resistance of 400 nm thick ATO (two layers) and ITO (one layer) coatings versus the sintering temperature is shown in Fig. 8. The values steadily decrease with the increase of the temperature. For ATO coating \( \rho \) reaches a minimum of \( 1.7 \times 10^{-2} \ \Omega \text{cm} \) \( (R_\Omega = 430 \ \Omega) \) at 550°C. The resistivity of ITO coatings decreases continuously down to \( \rho = 1.5 \times 10^{-2} \ \Omega \text{cm} \) \( (R_\Omega = 380 \ \Omega) \) at 900°C. A postannealing of ITO coatings in nitrogen at a temperature of 300°C reduces the resistivity and values as small as \( \rho = 3.4 \times 10^{-3} \ \Omega \text{cm} \) \( (R_\Omega = 90 \ \Omega) \) are obtained for sintering at 900°C.

A study of the long term stability of ITO films sintered at 550°C, stored in air at 20°C and 40% relative humidity, is shown in Fig. 9. The sheet resistance of the as sintered coating practically fluctuates around 2 k\( \Omega \). The sheet resistance of the annealed ITO coating slightly and steadily increases with time. After 40 days, \( \rho \) reaches a value of \( 2.9 \times 10^{-3} \ \Omega \text{cm} \) almost three times higher than the value measured immediately after annealing \( (9.7 \times 10^{1} \ \Omega \text{cm}) \). The reason for the increase in the resistivity of these coatings lays in their high porosity. Oxygen from the surrounding air diffuses into the coatings through the pores and partly eliminates the effect of the annealing.

For most applications a high transmission in the visible range is also important. A typical example of the transmission and reflection properties of 400 nm thick ATO and ITO coatings is shown in Fig. 10. The transmission in the visible range measured against air is about 90%. This reflects the beneficial effect of using particles in the nanometer range for coating production as these particles practically do not scatter the visible light. The annealed ITO and ATO coatings show a similar increase of the reflectance in the IR range due to the conducting properties of the materials. However, the deposited ITO film has a lower reflectance due to the lower density of the electrons.

Gasparro et al. found that different deposition and heating conditions have a strong influence on the morphology of the coatings [10]. Each layer of single and multilayer coatings
obtained with sols containing crystalline nanoparticles presents a thin (<10 nm) dense interface (external part) lying on top of a more porous material (internal part). The layers are composed of small crystallites (Fig. 11). For ATO coatings the surface of the layer is very smooth compared to the ATO and ITO coatings made by sol-gel or sputtering technique (Table 1). This is due to the very small particles (4 nm) used to obtain the coatings.

The morphology of the coatings has an influence on the porosity and on the electrical parameters of the coatings. Sintered ATO powders [11] have a total porosity of 63% practically independent of the sintering temperature. The pore size distribution is narrow and the average value of the pore diameter shifts from 4 nm (400°C) to 20 nm (800°C) for increasing sintering temperature. The porosity of ATO coatings measured at different temperatures by surface acoustic wave measurements (SAW) shows the same behaviour (Fig. 12). Due to the high porosity the electrons are scattered at the grain boundaries of the particles, leading to a low mobility and a high resistivity. The particulate nature of the ATO and ITO layers explains why the resistivity is still a factor 10 (for ITO) and 100 (for ATO) higher than coatings prepared by physical techniques.

4. Conclusion

Crystalline SnO₂, SnO₂:Sb and In₂O₃:Sn nanoparticles, fully dispersible in water or ethanol have been prepared. The growth of the particles was controlled in an aqueous ammonia solution by chemical modification of the particle surface. The obtained suspension are stable at pH > 8 for ATO and pH < 6 for ITO. Transparent conducting coatings with thickness up to 500 nm/layer have been obtained by spin coating (ATO, ITO) and dip coating (ITO) process. The resistivity of SnO₂:Sb and In₂O₃:Sn coatings depends on the sintering temperature and annealing processes. For ATO the lowest value of $\rho = 1.7 \times 10^{-2}$ Ω cm was obtained at a sintering temperature of 550°C while for ITO layers the lowest resistivity $\rho = 2 \times 10^{-2}$ Ω cm was obtained after sintering at 900°C. This value was reduced to $\rho = 3.4 \times 10^{-3}$ Ω cm after annealing at 300°C in nitrogen atmosphere. The resistivity and consequently the sheet resistance are still a factor 100 (ATO) and 10 (ITO) higher than those obtained by sputtering, CVD or spray pyrolysis processes [12] but the optical transmission of the coatings in the visible range is better (>90%).

Nevertheless the use of crystalline ATO and ITO nanpowders offers a new way to produce large transparent conducting coatings for antistatic application or for devices requiring sheet resistance larger than about 300 Ω/square as touch screen panels. The nanoscaled porosity of these materials which limits the electrical characteristics turn them interesting for the preparation of thick conducting membranes for ultrafiltration [11].

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References